

INTERNATIONAL  
GEMOLOGICAL  
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

December 13, 2025

IGI Report Number  
Description  
Shape and Cutting Style  
Measurements

LG749575272  
LABORATORY GROWN DIAMOND  
OVAL BRILLIANT  
10.49 X 7.28 X 4.23 MM

GRADING RESULTS

Carat Weight  
Color Grade  
Clarity Grade

2.00 CARATS  
E  
VS 1


ADDITIONAL GRADING INFORMATION

Polish  
Symmetry  
Fluorescence

EXCELLENT  
EXCELLENT  
NONE

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

 LG749575272

Report verification at igi.org

PROPORTIONS

Medium To Thick (Faceted)

60%

12%

42%

58.1%

Pointed

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

Red symbols indicate internal characteristics.  
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light


CLARITY

FL IF VVS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

Sample Image Used

LABORATORY GROWN DIAMOND REPORT



December 13, 2025

IGI Report Number  
Description  
Shape and Cutting Style  
Measurements

LG749575272  
LABORATORY GROWN DIAMOND  
OVAL BRILLIANT  
10.49 X 7.28 X 4.23 MM


GRADING RESULTS

Carat Weight  
Color Grade  
Clarity Grade


2.00 CARATS  
E  
VS 1

ADDITIONAL GRADING INFORMATION

Polish  
Symmetry  
Fluorescence  
Inscription(s)

EXCELLENT  
EXCELLENT  
NONE  
 LG749575272

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



IGI

December 13, 2025

IGI Report No LG749575272

OVAL BRILLIANT

10.49 X 7.28 X 4.23 MM

2.00 CARATS

E

VS 1

58.1%

60%


Medium To Thick (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

 LG749575272

Culet


Polish

Symmetry


Fluorescence

Inscription(s)


Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



© IGI 2020, International Gemological Institute



FD - 10 20



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.